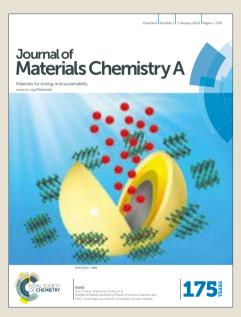
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Enhanced Li-ion Dynamics in Trivalently Doped Lithium Phosphidosilicate Li₂SiP₂: A Candidate Material as a Solid Li Electrolyte[†]

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Oxide and sulphide solid electrolyte materials have enjoyed significant interest in the solid-state battery community. Phosphide materials however are relatively unexplored despite the potential for being high lithium containing systems. This work reports on the phosphidosilicate system Li₂SiP₂, one of many systems in the Li-Si-P phase diagram. The phosphidosilicates display complex structures and very large unit cells, which present challenges for ab-initio simulations. We present the first computational report on the theoretical ionic conductivity and related diffusion mechanisms of the material Li₂SiP₂, selected due to it's unusual supertetrahedral framework which is a recurrent motif amongst the phosphidosilicates. Group 13 dopants have also been introduced into Li₂SiP₂ showing preference for the silicon site over the lithium site, with Al'Si doping showing extremely low defect incorporation energies of 0.05 eV, with no increase in defect energy up to concentrations of 10% Al'si. Furthermore, clustering of Al'si has been found to be unfavourable, in line with trends seen in oxide zeolite structures. Ab-initio molecular dynamics (AIMD) simulations indicate high ionic conductivity in pure Li_2SiP_2 of up to $3.19 \times 10^{-1}~\text{S.cm}^{-1}$ at 700 K. Doping with 10% Al'si and associated Li^o compensating defects leads to higher ionic conductivities at lower temperatures when compared to pure Li₂SiP₂. The activation energies to lithium diffusion were found to be low at 0.30 eV and 0.24 eV for pure and 10% Al_{Si}' doped Li₂SiP₂ respectively, in line with previous experimental observations of pure Li₂SiP₂. Multiple lithium migration pathways have also been extracted, with some mechanisms displaying activation energies as low as 0.05 eV. Furthermore, our calculated intercalation voltages suggest that these materials are stable against lithium metal and therefore could be very attractive in stabilising the electrode/electrolyte interface.

1 Introduction

Lithium batteries are a ubiquitous part of modern life and have facilitated a revolution in personal electronics. Safety concerns due to the current liquid electrolyte, however, have inhibited further development of their use as large scale grid storage devices. In order to continue this revolution, new battery materials, architectures and technologies are being developed and the field has gained quite some traction, with all solid state batteries taking

Solid state batteries have advantages in volumetric energy density relative to current lithium-ion batteries and improved safety due to the chemical stability of solid electrolytes. Li-ion solid-state conductors require high ionic conductivity at room temperature and low activation energy (Ea) for use over a broad range of operating temperatures. In addition, other properties such as electrochemical stability against the anode and cathode, and environmental stability are preferred as they reduce the complexity of the battery. $^{\rm 1}$ In the last decade, sulphide systems have been of growing interest due to the discovery of thio-LISICON type lithium superionic conductors with reported ionic conductivity of 12 mS.cm $^{\rm -1}$ at room temperature. $^{\rm 2-4}$

More recently, a range of lithium phosphidosilicate systems have been reported as promising candidates for solid Li ion conducting electrolytes due to their high Li compositions. ^{8–10} The high negative charge of the phosphide anion allows a higher cation Li⁺ content which leads to unique crystal structures which

centre stage. 1-7

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may also exhibit high Li ion diffusion. A list of the structure types adopted by the alkali metal phosphidosilicates is reported in Table 1 highlighting the complex relationship between the different crystal structures and activation energies and hence Li ion diffusion.

In 2016 Haffner *et al.* ⁸ reported the synthesis of two new materials, $\mathrm{Li_2SiP_2}$ and $\mathrm{LiSi_2P_3}$. Both materials contain large interlinked networks of supertetrahedra of silicon and phosphorous ($\mathrm{SiP_4}$). The charge compensating lithium ions are located within the spaces between the supertetrahedra. The lithium ion diffusion in both of these materials was investigated by temperature-dependent ⁷Li solid-state MAS NMR spectroscopy and reported to be very competitive with Li migration barriers as low as 0.1 eV for $\mathrm{Li_2SiP_2}$ and 0.07 eV for $\mathrm{LiSi_2P_3}$, making them promising candidates for solid Li electrolyte applications.

Soon after, Toffoletti *et al.* ⁹ elucidated the structure of another lithium containing phosphidosilicate, Li₈SiP₄, along with confirmation of the Li₂SiP₂ structure. These systems were found to have ionic conductivities of between 1.15×10^{-6} Scm⁻¹ at 0 °C and 1.2×10^{-4} Scm⁻¹ at 75 °C for Li₈SiP₄ and between 6.1×10^{-8} Scm⁻¹ at 0 °C and 6.0×10^{-6} Scm⁻¹ at 75 °C for Li₂SiP₂. The energy barriers to lithium diffusion were also determined by temperature-dependent ⁷Li solid-state MAS NMR spectroscopy and found to be 0.373 eV for Li₈SiP₄ and 0.487 eV for Li₂SiP₂. ⁹ However, Haffner *et al.* report an activation energy of 0.1 eV for Li₂SiP₂, indicating the sensitivity of this system to synthesis conditions.

Two more materials in the Li-Si-P system have also recently been reported by the same group, $\mathrm{Li_{10}Si_{2}P_{6}}$ and $\mathrm{Li_{3}Si_{3}P_{7}}$. ¹⁰ The interesting chemistry within the Li-Si-P systems is extremely varied with several structures showing high lithium content and low energy barriers to lithium diffusion and therefore ideal for a computational study such as this work. In this work we focus on $\mathrm{Li_{2}SiP_{2}}$ (LSP) where the structure is well known and manageable in terms of crystal structure size and computational expense.

1.1 Structure of Li₂SiP₂ (LSP)

In LSP the framework is comprised of corner-linked ${\rm Si_4P_{10}}^{14-}$ supertetrahedra, which are then assembled into two entwined 3D networks, see Figure 1. Each of these 3D networks has the same structure as the ${\rm SiP_4}^{8-}$ tetrahedra formed in the chalcopyrite structured material MgSiP $_2$ 15, but with ${\rm Si_4P_{10}}^{14-}$ replacing ${\rm SiP_4}^{8-}$. The charge balancing Li $^+$ occupy the interstitial spaces of the entwined networks in clearly defined locations, however unoccupied interstitial sites are also available (based on the Li $_2$ SiN $_2$ structure). 8,16 Experimentally the energy barriers to lithium diffusion in LSP were measured to be between 0.1-0.487 eV, however some disagreement remains about the exact value of the energy barrier, Table 1.8,9

There is one symmetrical Si^{4+} site (32g), situated within the supertetrahedra of the LSP structure, Figure 2 a). In contrast, three distinct Li^+ sites are identified in the interstitial space. Li^+ site 1 (16f) is located at the centre of a $\mathrm{LiP_4}^{11-}$ tetrahedra, with the $\mathrm{P^{3-}}$ ions being located at the edges of different $\mathrm{Si_4P_{10}}^{14-}$ supertetrahedra within the structure. $\mathrm{Li^+}$ site 2 (32g) is located at the centre

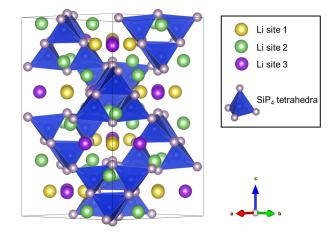


Fig. 1 The structure of Li₂SiP₂ showing the intertwined 3D networks with Li distributed in the interstitial spaces.

of a distorted ${\rm LiP_4}^{11-}$ tetrahedra, with three ${\rm P_3}^-$ ions comprising the face of a supertetrahedra. ${\rm Li}^+$ site 3 (16f) shares a channel with the ${\rm Li}^+$ site 1 and is also 4-fold coordinated but in a buckled square-planar arrangement.

2 Methodology

2.1 DFT methodology

All our DFT calculations were performed using the Vienna Ab initio Simulation Package (VASP) 17 using the projector augmented wave (PAW) method 18 and the PBEsol 19 functional. All calculations were spin polarised. Long-range dispersion corrections have not been included as the constituent ions are relatively small and such interactions will be effectively screened in a condensed solid. Lattice vectors were allowed to vary during minimisations and a force tolerance of 1.0×10^{-2} eV.Å $^{-1}$ was applied for convergence. The calculated lattice parameters are all within 1% of the experimental lattice parameters determined by both Toffoletti $et\ al.$ 9 and Haffner $et\ al.$ 8 . Further details of the computational parameters are available in the SI.

Final lattice energies were obtained by single point calculation on the optimised structures, using the more accurate reciprocal space projection scheme 17 with electronic convergence set to a tolerance of $1.0\times 10^{-8}\,$ eV. As the calculation of defect energies requires taking the difference of two very large numbers, the computed lattice energies must be extremely precise. To this end, we have selected a very high plane wave energy cutoff of 1000 eV for all calculations unless stated otherwise.

To ensure calculated defect energies are accurate and not influenced by finite size effects, three sizes of LSP supercell were created. These supercells contain 160, 320 and 640 atoms and are referred to as LSP-160, LSP-320 and LSP-640 respectively see SI). All materials and supercells had their convergence with respect to plane wave energy cutoff and k-point grid tested, optimised settings are available in the SI. In order to simplify the defect calculations, compensating defects were introduced into the same simulation cell as nearest neighbours to the dopant species. This reduces the configurations which require checking, but means that the defect energies quoted include a contribution due to defect

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| Material | Framework structure | Space group | Activation energy (eV) | Reference |
|---|--|------------------------|------------------------|-----------|
| LiSi ₂ P ₃ | Supertetrahedral framework | $I4_1/a$ (88) | 0.07 | 8 |
| Li ₂ SiP ₂ | Supertetrahedral framework | $I4_1/acd$ (142) | 0.10-0.487 | 8,9 |
| Li ₈ SiP ₄ | Isolated SiP ₄ ⁸⁻ tetrahedra | $Pa\overline{3}$ (205) | 0.373 | 9 |
| $\text{Li}_3\text{Si}_3\text{P}_7$ | Corner linked SiP ₄ ⁸⁻ tetrahedra with P-P bonds | $P2_1/m$ (11) | not reported | 10 |
| $\text{Li}_{10}\text{Si}_{2}\text{P}_{6}$ | Isolated Si ₂ P ₆ ¹⁰⁻ double tetrahedra | $P2_1/n$ (14) | not reported | 10 |
| Na ₁₀ Si ₂ P ₆ | Isolated Si ₂ P ₆ ¹⁰⁻ double tetrahedra | $I4_1/acd$ (14) | not reported | 11 |
| Na ₁₉ Si ₁₃ P ₂₅ | Supertetrahedral framework | $P\overline{1}$ (2) | 0.36 | 12 |
| $Na_{23}Si_{19}P_{33}$ | Supertetrahedral framework | C2/c (15) | 0.47 | 12 |
| $Na_{23}Si_{28}P_{45}$ | Supertetrahedral framework | $P2_1/c$ (14) | 0.38 | 12 |
| Na ₂₃ Si ₃₇ P ₅₇ | Supertetrahedral framework | C2/c (15) | 0.37 | 12 |
| LT-NaSi ₂ P ₃ | Supertetrahedral framework | $I4_1/a$ (88) | 0.23 | 12 |
| HT-NaSi ₂ P ₃ | Supertetrahedral framework | $I4_1/acd$ (142) | 0.25 | 12 |
| K_2SiP_2 | 1D SiP ₂ ²⁻ chains | Ibam (72) | not reported | 13 |
| KSi_2P_3 | 2D Si ₂ P ₃ ¹⁻ layers | C2/c (15) | not reported | 14 |

a) Si site

b) Li sites

Site 1 Site 2 Site 3

Fig. 2 Two cation sites available within Li₂SiP₂, a) a single Si site and b) three distinct Li sites. For legend see Figure 1.

clustering.

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To obtain more accurate electronic properties, such as the band gap, electronic Density of States (DOS) and intercalation/deintercalation voltages a hybrid functional, HSE06, 20 was used instead of the PBEsol GGA functional. The DOS were calculated using a single point HSE06 calculation at the full $3\times3\times2$ k-point grid with a 1000 eV plane wave cutoff. The lithium intercalation/deintercalation voltages are also calculated using the HSE06 functional, but use only the Γ -point and a reduced 700 eV cutoff. All hybrid HSE06 calculations were performed on the LSP-160 atom simulation cell.

2.2 Ab-initio Molecular dynamics (AIMD)

Since energy minimisation methods yield the lattice constants of the LSP systems equivalent to those of a 0 K system, neglecting zero-point motion, a different approach must be used to obtain the lattice constants at temperature. The correct volume at each temperature was obtained using Langevin dynamics 21 via AIMD. The Parrinello and Rahman was employed in this work. 22,23 In this approach, the atomic velocities are adjusted via a stochastic process emulating Brownian motion of a fictional solvent, Equation 1.

$$\dot{p}_i = F_i - \gamma_i p_i + f_i \tag{1}$$

where F_i is the force on particle i, γ_i is a friction coefficient, p_i is

the momentum, $\dot{p_i}$ is the time derivative of the momentum, f_i is a random force. The random force, f_i , has dispersion σ_i and is related to the friction coefficient by Equation 2.

$$\sigma_i^2 = \frac{2m_i \gamma k_B T}{\Delta t} \tag{2}$$

By tuning the coupling parameters of the Langevin dynamics, the process acts as a thermostat and is able to control the temperature of the real system, thereby approximating a canonical ensemble. Additionally, the lattice degrees of freedom are also coupled to the Langevin equations, allowing them to evolve over time. The advantage of this approach is that the fluctuations of the lattice degrees of freedom may be carefully controlled, counterbalancing the large fluctuations expected when a system of less than 1,000 atoms is considered.

Although Langevin dynamics are useful for obtaining the correct instantaneous averages, it fails to obtain correct time-correlated quantities such as diffusion coefficients. This stems from the random stochastic variable used to control the temperature. To obtain the correct diffusion coefficients for these systems a Nosé-Hoover thermostat is employed for the next stage of the canonical simulation. ^{24,25} From this data it is possible to extract a Mean Squared Displacement (MSD) for each species, using Equation 3.

$$MSD(t) = \langle (\vec{r}_i(t) - \vec{r}_i(0))^2 \rangle$$
 (3)

where $\vec{r}_i(t)$ is the position vector at time t and likewise $\vec{r}_i(0)$ is the initial position. Angled brackets denote an average employing a shifting time origin which can be used to further improve accuracy. The diffusion coefficients can then be extracted via the Einstein diffusion equation, Equation 4.

$$MSD(t) = 6Dt + C \tag{4}$$

where D is the diffusion coefficient and C is a constant. All AIMD simulations were performed in the LSP-320 simulation cell. A timestep of 0.5 fs was used for all AIMD simulations, with a reduced k-point grid utilising only the Γ -point and a reduced electronic cutoff of 700 eV.

3 Results

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3.1 Intrinsic defects

The most important intrinsic defect to consider in pure LSP with regards to lithium migration is the lithium Frenkel defect.

The Li Frenkel defect energy was calculated by taking an observed spontaneous Frenkel from the AIMD data and forming the same defect in a pure LSP-160 simulation cell. The pathway chosen was that of a site 1 lithium moving into an interstitial space in the site 2 pathway, and a site 3 lithium immediately migrating onto the vacant site 1. This observed Frenkel formation gives a defect energy of 0.769 eV. When the separation of the vacancy-interstitial pair is maximised within the supercell, retaining the same vacancy and interstitial sites, the defect energy increases to approximately 0.92 eV. The lithium Frenkel defect energies are relatively high compared to the Al'Si and Li^o defect pair energy calculated from Equation 5, indicating it is the lithium vacancy which is the greatest contribution to the lithium Frenkel energy.

3.2 Trivalent doping

To date, there has been little work done on the defect chemistry of the phosphidosilicates, however inspiration may be taken from zeolites which also demonstrate complex frameworks, although are more porous. The zeolites frequently incorporate aluminium defects into their structures ^{26,27}, although boron and gallium are also known to incorporate in some cases ^{28–30}. We have therefore opted to study the doping of Li₂SiP₂ with group 13 elements. In particular group 13 phosphides have been selected as the source of dopant ions as this greatly simplifies the possible defect compensating mechanisms. Thus, BP³¹, AlP³² and GaP³³, all Zinc blende structures, were selected as the source of dopant ions.

Doping of Li_2SiP_2 may occur on the Si^{4+} site or the three distinct Li^+ sites. Two compensating mechanisms have been considered and are given in Equations 5 and 6.

$$MP + Li_3P + Si_{Si}^x \longrightarrow M_{Si}' + Li_i^{\bullet} + Li_2SiP_2$$
 (5)

$$MP + 3Li_{Li}^{X} \longrightarrow M_{Li}^{\bullet \bullet} + 2V_{Li}' + Li_{3}P$$
 (6)

Equation 5 represents a group 13 element (M) doping on a silicon site, Figure 2 a), with the formation of a compensating $\operatorname{Li}_{i}^{\bullet}$ defect. As all Si^{4+} sites are equivalent under symmetry, the possible configurations are limited. Doping using Equation 6 is

more challenging as there are three distinct ${\rm Li}^+$ sites, each of which must be considered individually, Figure 2 b).

The defective LSP systems were created by taking the supercells outlined in the SI and inserting a single dopant atom on either the Si⁴⁺ site or the Li⁺ site.

The calculated defect energies for doping LSP with B^{3+} , Al^{3+} and Ga^{3+} using Equations 5 and 6 are presented in Table 2

Table 2 Defect energies using Equations 5 and 6

| Site | Supercell | B ³⁺ (eV) | Al ³⁺ (eV) | Ga ³⁺ (eV) |
|-----------|-----------|----------------------|-----------------------|-----------------------|
| | LSP-160 | 1.208 | 0.044 | 0.173 |
| Si site | LSP-320 | 1.226 | 0.049 | 0.180 |
| | LSP-640 | 1.225 | 0.051 | 0.182 |
| | LSP-160 | 4.307 | 1.947 | 2.076 |
| Li site 1 | LSP-320 | 4.362 | 1.974 | 2.100 |
| | LSP-640 | 4.352 | 1.961 | 2.087 |
| | LSP-160 | 3.682 | 1.976 | 2.084 |
| Li site 2 | LSP-320 | 3.714 | 1.969 | 2.077 |
| | LSP-640 | 3.744 | 1.970 | 2.076 |
| | LSP-160 | 3.598 | 2.512 | 2.579 |
| Li site 3 | LSP-320 | 3.674 | 2.528 | 2.584 |
| | LSP-640 | 3.679 | 2.508 | 2.566 |

The calculated defect energies indicate that trivalent doping is clearly more favourable on the Si^{4+} site than the Li^{+} site. Within the Si^{4+} site, Al^{3+} displays extremely low defect energies of ~ 0.05 eV which suggests there may be significant incorporation of aluminium in this material if a suitable source is available during synthesis. Ga^{3+} doping on Si^{4+} is the next most favourable doping strategy with a defect energy of ~ 0.18 eV, while doping with B^{3+} on Si^{4+} is the least favourable strategy using Equation 5 with a defect energy of ~ 1.22 eV.

The low incorporation energy of aluminium into the LSP structure, with reduced favourability of boron and gallium incorporation, mirrors the trends observed in zeolites. Aluminium frequently substitutes into zeolite structures of all types. 26,27,34 Although gallium also frequently incorporates to a significant degree, the larger ionic radius results in longer bond lengths and the preference to form slightly different zeolite structures. 30,34 This is mirrored in our results which show gallium is a less favourable dopant of LSP than aluminium, but still has a low enough defect energy to be able to incorporate, Table 2. Furthermore, boron has a significantly smaller ionic radius which leads to significantly shorter bond lengths and poor substitution for aluminium in zeolite frameworks. 28,34 Once again this is reflected in our results which show the defect energy of incorporating boron into the LSP structure is significantly higher than either aluminium or gallium, Table 2.

Doping on the Li $^+$ sites shows more variability between the dopant species, Table 2. Once again Al $^{3+}$ is the most favourable dopant across all Li $^+$ sites, with the tetrahedral sites 1 and 2 preferred (\sim 1.97 eV) over the non-tetrahedral site 3 (\sim 2.51 eV). Ga $^{3+}$ doping follows much the same trend as Al $^{3+}$ doping with defect energies of \sim 2.07 eV across tetrahedral sites 1 and 2 while the non-tetrahedral site 3 has a defect energy of \sim 2.57 eV. Interestingly, B $^{3+}$ doping on the Li $^+$ sites does not follow this trend and instead the non-tetrahedral site 3 is the most stable Li $^+$ site defect (\sim 3.67 eV) with site 2 being of a similar energy (\sim 3.73 eV)

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and site 1 being considerably higher (\sim 4.36 eV). This unusual reversal of the favoured doping sites is likely due to the small size of the B³⁺ cation³⁵ and larger distortion of the four supertetrahedra coordinating Li⁺ site 1, while sites 2 and 3 involve a smaller distortion of the framework in order to fully coordinate the B³⁺ dopant.

3.3 Defect clustering

To probe the limit of Al'si dopant clustering, nine different systems were created using the LSP-320 simulation cell, each with six randomly distributed Al'si defects. An additional system was created with four Al'_{Si} defects forming a whole supertetrahedra, with the remaining two Al'si defects placed randomly in the system. The resulting concentration of Al's defects in these systems is 9.375 %. Charge compensating Li⁺ interstitial defects have not been included in these calculations as this would introduce a secondary configurational contribution to the energy which would be extremely challenging to disentangle from the effects of aluminium clustering.. However, the total number of electrons in these calculations has been set so that the supertetrahedral frameworks retain the correct charge. This setup ensures the limit of Al'si clustering is thoroughly probed and that the energy differences between the systems are due to the effects of clustering of Al'_{Si} defects alone, excluding the effects of compensating Li^{*}_i species. An example simulation cell is given in Figure 3.

To measure the degree of Al_{Si}' clustering in Al doped LSP, we consider only adjacent Si^{4+} sites, the degree of clustering may be given by the number of P^{3-} ions shared by Al^{3+} ions. Plotting the relative lattice energies against this metric gives the graph in Figure 4.

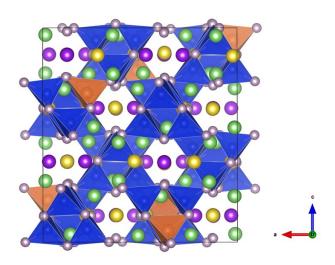


Fig. 3 Example LSP-320 simulation cell with 6 ${\rm Al}_{\rm Si}'$ defects (orange tetrahedra).

These results show a clear trend of higher clustering of Al_{Si}' resulting in less stable systems. However, the energy per Al_{Si}' defect is small. The most stable system has the Al_{Si}' defects distributed evenly in space and across the two supertetrahedral frameworks. In contrast, the additional system constructed as to have a single

superterahedra containing only Al'_{Si} defects is the least stable.

By inserting the missing L_i^{\bullet} interstitials into the most stable Al'_{Si} doped system, the defect energy can be calculated as before. Ordering of Li_i^{\bullet} interstitials is now less certain due to the random placement of Al'_{Si} defects and so the Li_i^{\bullet} interstitials are inserted randomly.

The defect energies from these calculations are thus not exactly comparable to those presented in Table 2 but may act as an upper bound on the defect energy in these highly doped systems. Performing this calculation gives a defect energy of 0.062 eV per Al_{Si}^{\prime} and Li_{i}^{\bullet} pair. This energy is only 0.01 eV higher than for the case of a single Al_{Si}^{\prime} defect in an equivalently sized cell (Table 2), indicating tolerance to high defect concentrations in $Li_{2}SiP_{2}$.

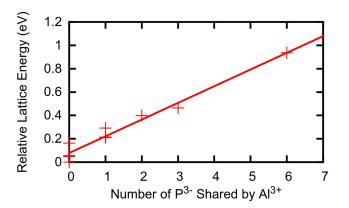


Fig. 4 Relative lattice energies of Al_{Si}' doped systems against number of shared P^{3-} ions.

3.4 Lithium diffusion

To investigate the lithium diffusion properties within the pure and Al-doped LSP systems, ab-initio molecular dynamics (AIMD) calculations were performed. Four systems in total were simulated; two pure $\mathrm{Li_2SiP_2}$ and two $\mathrm{Al'_{Si}}$ doped systems. The Al doped systems selected were the globally most stable and the most stable with one shared $\mathrm{P^{3-}}$ ion. Different starting velocities were used for each systems during initialisation to ensure different regions of phase space were explored.

An AIMD calculation using a Langevin thermostat was performed on each of the 4 systems at 5 different temperatures, for a total duration of 5 ps each. The average lattice vectors were calculated by taking the second half of the Langevin AIMD simulations and averaging the lattice vectors over time. The average cell volume produced for the pure and doped systems via Langevin MD are presented in the SI.

Using the results of the Langevin dynamics the average volume of each system at equilibrium was obtained. The volumes of the two pure systems can be considered to be probing different regions of the same phase space and so have been averaged together. However, The equilibrium volumes for the two doped systems are for different defect configurations and so are probing different phase spaces, and are thus kept separate.

The volume scaled lattice parameters were next applied to the

simulation cells and kept fixed for the next phase of calculation. A Nosé-Hoover thermostat was also employed instead of a Langevin thermostat and the simulations were run for a further 5 ps each. The velocities were then discarded to remove spurious contributions introduced by the rescaling of the lattice vectors. An additional 20 ps of AIMD were then performed. The calculated MSDs indicate significant movement of lithium ions, but no movement of either silicon or phosphide ions, indicating the system is stable even at 700 K. The full MSDs are available in the SI. The Li component of the MSDs, averaged across the pure or defective systems, are shown in Figure 5.

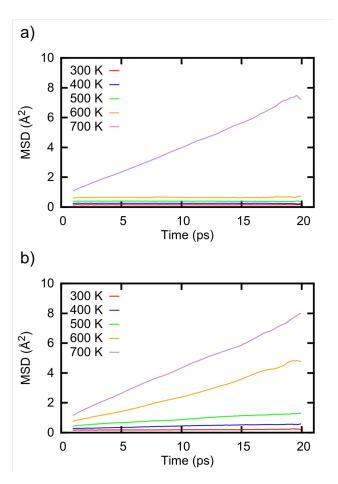


Fig. 5 MSD of lithium at all temperatures for a) pure and b) ${\rm Al}'_{\rm Si}$ doped LSP.

Pure LSP, Figure 5 a), shows significant Li diffusion only at 700 K. However, the diffusion of Li in Al $_{Si}'$ doped LSP, Figure 5 b), is significantly increased down to 500 K. The increase in Li diffusion may be attributed to the inclusion of Li $_{i}^{\bullet}$ defects.

The ionic conductivity measured experimentally includes correlated motion of the diffusing species which is absent when the tracer diffusion coefficient is measured via the MSD. The experimentally measured ionic conductivities may be related to the computed diffusion coefficients via a simple ratio, often referred to as a Haven ratio. ³⁶ The relationship between computed tracer diffusion coefficients and the ionic conductivity is given by Equation 7.

$$\sigma = \frac{DCq^2}{k_B T} \frac{1}{H_R} \tag{7}$$

where D is the tracer diffusion coefficient obtained from AIMD via the MSDs, C is the concentration of the diffusing species (lithium ions), q is the charge of the diffusing species, H_R is the Haven ratio, T is the temperature and k_B is the Boltzmann constant. 37,38

We have adopted a Haven ratio of 1.0 for Al_{Si}^{\prime} doped LSP based on the dominance of Li interstitial defects ³⁹ and therefore suppression of vacancy formation and diffusion. For simplicity we have also adopted a value of 1.0 for the pure LSP system. Both the diffusion coefficients and ionic conductivities are given in Table 3.

The ionic conductivity of LSP was measured experimentally by Toffoletti *et al.* ⁹ within the range 273.15-348.15 K. In order to compare our computed ionic conductivities we have extrapolated the experimental values into the range 300-700 K. The extrapolation produces an overall excellent agreement between experimental and computed ionic conductivity of pure LSP, with the sole exception of the computed value at 300 K which is much higher than expected. It must be noted, however, that calculation of diffusion at lower temperatures is challenging using AIMD due to the relatively few diffusion events which are occurring within the simulated timeframe, leading to large uncertainties in the diffusion coefficients. Indeed, examination of Figure 6 shows that pure LSP at 300 K is the only value significantly deviating from a linear trend.

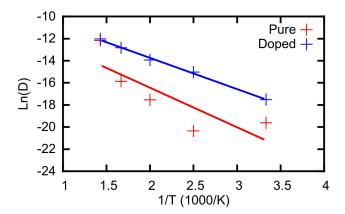


Fig. 6 Arrhenius plot for pure and Al'_{Si} doped LSP.

The Arrhenius plot also displays good linearity for the Al_{Si}^{\prime} doped system. At temperatures below 700 K the Al_{Si}^{\prime} doped systems display 1-2 orders of magnitude higher diffusion. The activation energies extracted from Figure 6 were 0.30 eV for pure Li_2SiP_2 and 0.24 eV for Al_{Si}^{\prime} doped Li_2SiP_2 . It is interesting to note that taking only the highly linear portion of the Arrhenius plot between 400-600 K for pure LSP results in an activation energy of 0.47 eV, almost identical to the experimental value of 0.487 eV.

The high diffusion coefficients observed in pure LSP at 700 K is rather unusual and cannot be simply explained as poor statistical averaging. By inspecting the trajectory of a pure 700 K AIMD simulation at least one high throughput lithium conduction pathway can be identified, Figure 7. Utilisation of this pathway during the

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Table 3 Calculated diffusion coefficients and ionic conductivity of pure and Al doped LSP

| | Diffusion coefficient (cm ² .s ⁻¹) | | Ionic conductivity (S.cm ⁻¹) | |
|-----------------|---|-----------------------|--|-----------------------|
| Temperature (K) | Pure LSP | Doped LSP | Pure LSP | Doped LSP |
| 300 | 3.01×10^{-9} | 2.44×10^{-8} | 4.36×10^{-4} | 3.71×10^{-3} |
| 400 | 1.45×10^{-9} | 3.00×10^{-7} | 1.58×10^{-4} | 3.42×10^{-2} |
| 500 | 2.38×10^{-8} | 8.74×10^{-7} | 2.07×10^{-3} | 7.96×10^{-2} |
| 600 | 1.29×10^{-7} | 2.67×10^{-6} | 9.38×10^{-3} | 2.03×10^{-1} |
| 700 | 5.14×10^{-6} | 5.98×10^{-6} | 3.19×10^{-1} | 3.89×10^{-1} |

simulation may explain the sudden increase in diffusion at 700 K. This pathway may not be active all the time, which would lead to a reduced diffusion coefficient if pure LSP is simulated over longer timescales.

The pathway shown in Figure 7 b) corresponds to a highly curved 1-dimensional chain of Li⁺ site 2, Figure 7 a). These pathways occur in parallel with a given layer of the Li₂SiP₂ structure, and then reoccur rotated by 90 degrees in the layers above and below. Utilisation of this pathway by lithium ions was observed multiple times in several of the AIMD simulations, indicating it may be the origin of the high conductivity observed in Li₂SiP₂.

The site 2 pathway in Figure 7 corresponds to an interstitial mechanism, instigated by the spontaneous creation of a lithium Frenkel pair. The Frenkel pair is created by a lithium ion moving from a lithium site 1 into an interstitial space in the lithium site 2 pathway, Figure 7 b). The vacancy located on lithium site 1 is immediately filled by diffusion of another lithium atom from a lithium site 3, thereby blocking the return of the original site 1 lithium, Figure 7 c). It is interesting to note that the AIMD pathway observed in Figure 7 b) does not show segmentation with higher density at the original Li sites, but is rather a continuous band of lithium density, suggesting the lithium ions in the pathway are not strongly bound to the original sites.

The same continuous band of lithium positions is always observed in Al'_{Si} doped LSP, Figure 8, suggesting the presence of Al'_{Si} defects do not act as a trap for diffusing lithium ions. This is unsurprising given the relatively small difference in charges between Si^{4+} and Al^{3+} .

To probe this unusual pathway further, Nudged Elastic Band (NEB) calculations were performed within a pure LSP-160 simulation cell. 40,41 Al'si defects were not included in the NEB calculations due to the observed similarity with Si_{Si}^{X} (i.e. no clustering of defects) and to reduce the number of factors under consideration. From the AIMD data it is known that this pathway is usually activated by the presence of a lithium interstitial in the pathway, although stoichiometric and vacancy mechanisms were also probed. The NEB calculations show that the site 2 pathway is highly unlikely to be activated without defects present, as the activation barrier is on the order of 0.73 eV for a stoichiometric mechanism. However, once a defect is present, whether vacancy or interstitial, the activation barrier drops significantly. The site 2 vacancy mechanism has an activation barrier on the order of 0.22 eV, indicating it is a feasible mechanism for lithium migration. The most striking result however is the activation barrier for the interstitial pathway. By inserting a single Li interstitial into the site 2 chain, the activation barrier drops even further to 0.05 eV. It is this extraordinarily low barrier to lithium migration which accounts for the smooth distribution of lithium seen in the site 2 pathway, Figure 7. The migration pathway predicted for the interstitial site 2 pathway results in a very minimal disruption to the rest of the lattice, Figure 9, which somewhat accounts for the low energy barrier to migration. However, it must be noted that the site 2 pathway is 1-dimensional in the xy-plane and there may exist other low energy pathways for defects to move out of the pathway, significant increasing the activation energy of lithium migration along the pathway. Thus, the site 2 pathway may only be active under certain conditions, such as high Li content, and may only be active for relatively short periods of time and is therefore unlikely to dominate the 3-dimensional diffusion coefficients.

The vacancy component of the Frenkel pair formed in Figures 7 b) and c) travels via a much more complex pathway through the simulation cell than the interstitial component. Further NEB calculations have been performed into a number of lithium vacancy migration mechanisms, see SI. Importantly, the lithium vacancy mechanisms studied constitute a 3-dimensional network spanning the entire material. The majority of lithium vacancy migration mechanisms have activation energies of 0.2-0.3 eV, in strong agreement with the AIMD calculations, suggesting the 3-dimensional vacancy mechanisms may be dominating the long-range transport of lithium ions, particularly in pure LSP.

It is therefore conceivable that the introduction of $\operatorname{Li}_{\bullet}^{\bullet}$ defects boosts the site 2 interstitial pathway at low temperatures and leads to higher ionic conductivity; but as the temperature is increased, spontaneous lithium Frenkel defects are able to form and the presence of additional $\operatorname{Li}_{\bullet}^{\bullet}$ defects leads to a suppression of the vacancy pathways and results in ionic conductivity values on-par with pure LSP.

3.5 Electronic properties

The Al doped system used contains a single Al defect and associated Li interstitial. No effect on the bandgap or the nature of the VBM or CBM was observed, see the SI. The bandgap is calculated to be approximately 2.4 eV for both pure and doped systems.

It is also possible to calculate the voltage obtained by inserting or removing additional Li ions into the LSP structure. The voltage gained from intercalation of a single additional lithium into the LSP structure is given by Equation 8, where V_{int} is the intercalation voltage, E(x) denotes the lattice energy of material x, F is the Faraday constant and Li denotes metallic lithium.

$$V_{int} = \frac{-[E(\text{Li}_{65}\text{Si}_{32}\text{P}_{64}) - E(\text{Li}_{64}\text{Si}_{32}\text{P}_{64}) - E(\text{Li})]}{F}$$
(8)

Likewise, Equation 9 gives the voltage obtained from deintercalating a single lithium from the LSP structure, V_{deint} .

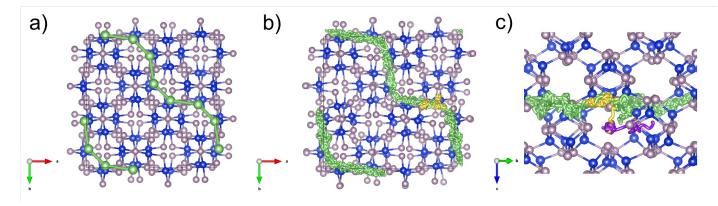


Fig. 7 The LSP-320 cell, displaying a) the lithium site 2 chain involved in the interstitial diffusion mechanism, b) the pathway extracted from the AIMD calculations and c) the same pathway viewed from the side with instigating spontaneous lithium Frenkel defect.

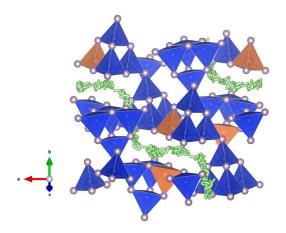


Fig. 8 A 2.5 ps segment of an AIMD simulation, showing the site 2 diffusion pathway in LSP-320 with Al'_{Si} defects. The simulation shows no clustering of lithium with the Al'_{Si} defects.

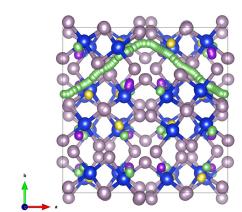


Fig. 9 The interstitial site 2 pathway as calculated by NEB in the LSP-160 simulation cell with a migration barrier of 0.05 eV. Note the minimal disruption to the rest of the lattice during the migration.

$$V_{deint} = \frac{-[E(\text{Li}_{63}\text{Si}_{32}\text{P}_{64}) + E(\text{Li}) - E(\text{Li}_{64}\text{Si}_{32}\text{P}_{64})]}{F} \tag{9}$$

The voltage generated by adding a single Li to form Li₆₅Si₃₂P₆₄ is approximately -0.46 V. The voltage generated by removing a single Li to form $\text{Li}_{63}\text{Si}_{32}\text{P}_{64}$ is approximately -2.72 V. LSP is therefore stable against Li metal under standard conditions. It must be noted that these values are only for a single lithium intercalation/de-intercalation process and the behaviour of the redox potential at greater/lesser lithium content is unknown.

Conclusions

In conclusion, trivalent doping of Li₂SiP₂ is most likely to occur on the Si⁴⁺ site rather than the Li⁺site. Aluminium doping on the silicon site with a charge compensating lithium interstitial is an extremely low energy doping mechanism with an energy barrier to incorporation of ~ 0.05 eV. Via this mechanism, the charge compensating Li^o species instigates increased lithium diffusion. Furthermore, doping of up to \sim 9 % Al'_{Si} is possible with very little change in energy per defect pair (+0.01 eV).

The AIMD simulations reveal a high throughout pathway for Li⁺ diffusion involving only lithium on site 2. This highly curved pathway is however only observed to activate upon migration of a lithium interstitial into the pathway. NEB calculations support the activation of the high-throughput pathway by interstitial Li, showing an exceptionally low energy barrier to migration of 0.05 eV when interstitial Li is included. The migration barriers were significantly higher in the site 2 pathway when the instigating mechanism is instead stoichiometric hops or vacancy hops.

Activation of the site 2 pathway, potentially by intrinsic as well as extrinsic defects, may be the origin of the high ionic conductivity observed experimentally. Future work will be concerned with exploring alternative doping schemes with an eye to generating lithium vacancies (with Mg²⁺). With diffusion data from lithium vacancies it then becomes possible to definitively ascertain any anisotropy in diffusion arising from either interstitial or vacancy lithium defects.

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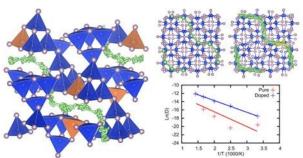
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The ionic conductivity and diffusion pathways of the supertetrahedral lithium phosphidosilicate Li₂SiP₂ are studied alongside the impact of trivalent doping.